

Akihiro Ohtake

List of Publications by Year in descending order

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1,725
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331670
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37
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93
all docs

93
docs citations

93
times ranked

1304
citing authors

#	ARTICLE	IF	CITATIONS
1	Surface reconstructions on GaAs(001). <i>Surface Science Reports</i> , 2008, 63, 295-327.	7.2	157
2	New Structure Model for the GaAs(001)-c(4Å-4) Surface. <i>Physical Review Letters</i> , 2002, 89, 206102.	7.8	110
3	Surface structures of GaAs{111}A,B-c(2Å-2). <i>Physical Review B</i> , 2001, 64, .	3.2	81
4	Self-Assembly of Symmetric GaAs Quantum Dots on (111)A Substrates: Suppression of Fine-Structure Splitting. <i>Applied Physics Express</i> , 2010, 3, 065203.	2.4	77
5	Kinetics in Surface Reconstructions on GaAs(001). <i>Physical Review Letters</i> , 2004, 92, 236105.	7.8	75
6	Surface phase transition and interface interaction in the $\hat{I}\pm$ -Sn/InSb{111} system. <i>Physical Review B</i> , 1994, 50, 7567-7572.	3.2	60
7	Atomic structure of the GaAs(001)-c(2Å-4) surface under As flux. <i>Physical Review B</i> , 2002, 65, .	3.2	60
8	Ga-Rich Limit of Surface Reconstructions on GaAs(001): Atomic Structure of the (4Å-6) Phase. <i>Physical Review Letters</i> , 2004, 93, 266101.	7.8	57
9	Two types of structures for the GaAs(001)-c(4Å-4) surface. <i>Applied Physics Letters</i> , 2003, 83, 5193-5195.	3.3	52
10	Strain Relaxation in InAs/GaAs(111)A Heteroepitaxy. <i>Physical Review Letters</i> , 2000, 84, 4665-4668.	7.8	48
11	Structure and composition of the ZnSe(001) surface during atomic-layer epitaxy. <i>Physical Review B</i> , 1999, 60, 8326-8332.	3.2	35
12	Overcoming metal-induced fluorescence quenching on plasmo-photonic metasurfaces coated by a self-assembled monolayer. <i>Chemical Communications</i> , 2015, 51, 11470-11473.	4.1	35
13	In situ observation of surface processes in InAs/GaAs(001) heteroepitaxy: The role of As on the growth mode. <i>Applied Physics Letters</i> , 2001, 78, 431-433.	3.3	34
14	Size-dependent line broadening in the emission spectra of single GaAs quantum dots: Impact of surface charge on spectral diffusion. <i>Physical Review B</i> , 2015, 92, .	3.2	33
15	Nature and origins of stacking faults from a ZnSe/GaAs interface. <i>Journal of Vacuum Science & Technology</i> an Official Journal of the American Vacuum Society B, Microelectronics Processing and Phenomena, 1997, 15, 1241.	1.6	30
16	Structure analysis of the Ga-stabilized GaAs(001)-c(8Å-2) surface at high temperatures. <i>Physical Review B</i> , 2002, 65, .	3.2	28
17	Gallium-rich reconstructions on GaAs(001). <i>Physica Status Solidi (B): Basic Research</i> , 2003, 240, 91-98.	1.5	27
18	Strain relaxation in InAs heteroepitaxy on lattice-mismatched substrates. <i>Scientific Reports</i> , 2020, 10, 4606.	3.3	27

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19	Characterization and control of II ^{VI} /III ^V heterovalent interfaces. <i>Journal of Crystal Growth</i> , 1998, 184-185, 163-172.	1.5	26
20	The role of zinc pre-exposure in low-defect ZnSe growth on As-stabilized GaAs (001). <i>Applied Physics Letters</i> , 1998, 73, 939-941.	3.3	25
21	Structural features of Ga-rich GaAs(001) surfaces: Scanning tunneling microscopy study. <i>Physical Review B</i> , 2004, 70, .	3.2	22
22	Polarity controlled InAs{111} films grown on Si(111). <i>Journal of Vacuum Science and Technology B:Nanotechnology and Microelectronics</i> , 2011, 29, .	1.2	20
23	Electrical characteristics and thermal stability of HfO ₂ metal-oxide-semiconductor capacitors fabricated on clean reconstructed GaSb surfaces. <i>Applied Physics Letters</i> , 2014, 104, .	3.3	20
24	Ga-richGaAs(001)surface from ab initio calculations: Atomic structure of the(4Å–6)and(6Å–6)reconstructions. <i>Physical Review B</i> , 2006, 73, .	3.2	19
25	Real-time analysis of adsorption processes of Zn on theGaAs(001)^(2Å–4)surface. <i>Physical Review B</i> , 1999, 60, 8713-8718.	3.2	18
26	Atomic structure of the Ga nanoclusters onSi(111)^(7Å–7). <i>Physical Review B</i> , 2006, 73, .	3.2	18
27	Extremely High- and Low-Density of Ga Droplets on GaAs{111}A,B: Surface-Polarity Dependence. <i>Crystal Growth and Design</i> , 2015, 15, 485-488.	3.0	18
28	Reflection high-energy electron diffraction analysis of the InSb{111}A,B-(2 Å– 2) surfaces. <i>Surface Science</i> , 1998, 396, 394-399.	1.9	17
29	Structure of Se-adsorbed GaAs(111)A-(23Å–23)-R30° surface. <i>Physical Review B</i> , 1999, 59, 8032-8036.	3.2	17
30	Ga-rich GaAs(001) surfaces observed by STM during high-temperature annealing in MBE. <i>Journal of Crystal Growth</i> , 2003, 251, 46-50.	1.5	17
31	Influence of initial surface reconstruction on the interface structure of HfO ₂ /GaAs. <i>Applied Surface Science</i> , 2008, 254, 7565-7568.	6.1	16
32	Structure and composition of Ga-rich(6Å–6)reconstructions on GaAs(001). <i>Physical Review B</i> , 2007, 75, .	3.2	15
33	Growth of Metamorphic InGaAs on GaAs (111)A: Counteracting Lattice Mismatch by Inserting a Thin InAs Interlayer. <i>Crystal Growth and Design</i> , 2016, 16, 5412-5417.	3.0	15
34	Two-Dimensional WSe ₂ /MoSe ₂ Heterostructures Grown by Molecular-Beam Epitaxy. <i>Journal of Physical Chemistry C</i> , 2021, 125, 11257-11261.	3.1	15
35	Non-Contact and Non-Destructive Measurement of Carrier Concentration of Nitrogen-Doped ZnSe by Reflectance Difference Spectroscopy. <i>Japanese Journal of Applied Physics</i> , 1997, 36, 6638-6644.	1.5	14
36	In situ determination of in-plane strain anisotropy in ZnSe(001)/GaAs layers using reflectance difference spectroscopy. <i>Journal of Vacuum Science & Technology an Official Journal of the American Vacuum Society B, Microelectronics Processing and Phenomena</i> , 1998, 16, 2342.	1.6	14

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37	Structures of the As-deficient phase on GaAs(001)-(2Å-4). <i>Physical Review B</i> , 2006, 74, .	3.2	14
38	Atomic structure and passivated nature of the Se-treated GaAs(111)B surface. <i>Scientific Reports</i> , 2018, 8, 1220.	3.3	14
39	Controlled incorporation of Mn in GaAs: Role of surface reconstructions. <i>Physical Review B</i> , 2013, 87, .	3.2	13
40	Droplet epitaxy growth of telecom InAs quantum dots on metamorphic InAlAs/GaAs(111)A. <i>Japanese Journal of Applied Physics</i> , 2015, 54, 04DH07.	1.5	13
41	Wurtzite-zinc-blende polytypism in ZnSe on GaAs(111)A. <i>Physical Review B</i> , 2001, 63, .	3.2	12
42	Effect of Substrate Orientation on MoSe ₂ /GaAs Heteroepitaxy. <i>Journal of Physical Chemistry C</i> , 2020, 124, 5196-5203.	3.1	12
43	Surface processes during heteroepitaxy of ZnSe on GaAs(111)Aas observed by reflection high-energy electron diffraction. <i>Physical Review B</i> , 1997, 56, 14909-14912.	3.2	11
44	Dependence of defect generation and structure on interface chemistry in ZnSe/GaAs. <i>Applied Surface Science</i> , 1997, 117-118, 495-502.	6.1	11
45	Self-assembled formation of ZnCdSe quantum dots on atomically smooth ZnSe surfaces on GaAs(001) by molecular beam epitaxy. <i>Thin Solid Films</i> , 1999, 357, 1-7.	1.8	11
46	Heteroepitaxy of GaSb on Si(111) and fabrication of HfO ₂ /GaSb metal-oxide-semiconductor capacitors. <i>Applied Physics Letters</i> , 2014, 104, .	3.3	11
47	Geometry and lattice formation of surface layers of Sn growing on InSb{111}A,B. <i>Physical Review B</i> , 1996, 54, 10358-10361.	3.2	10
48	ZnSe epitaxy on a GaAs(110) surface. <i>Applied Physics Letters</i> , 1997, 71, 1192-1194.	3.3	10
49	X-ray reflectivity from ZnSe/GaAs heterostructures. <i>Journal of Applied Physics</i> , 1999, 85, 1520-1523.	2.5	10
50	Adsorption of Zn on the GaAs(001)-(2Å-4) surface. <i>Applied Physics Letters</i> , 1999, 74, 2975-2977.	3.3	10
51	Ga-As dimer structure for the GaAs(001)-c(4Å-4) surface. <i>Surface Science</i> , 2004, 566-568, 58-62.	1.9	10
52	Self-assembled growth of ordered GaAs nanostructures. <i>Applied Physics Letters</i> , 2006, 89, 083108.	3.3	10
53	As-rich (2Å-2) surface reconstruction on GaAs(111)A. <i>Surface Science</i> , 2012, 606, 1864-1870.	1.9	10
54	Self-Assembled Growth of Ga Droplets on GaAs(001): Role of Surface Reconstructions. <i>Crystal Growth and Design</i> , 2014, 14, 3110-3115.	3.0	10

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55	Evolution of Surface and Interface Structures in Molecular-Beam Epitaxy of MoSe ₂ on GaAs(111)A and (111)B. <i>Crystal Growth and Design</i> , 2017, 17, 363-367.	3.0	10
56	Growth mode and defect generation in ZnSe heteroepitaxy on Te-terminated GaAs(001) surfaces. <i>Journal of Vacuum Science & Technology</i> an Official Journal of the American Vacuum Society B, <i>Microelectronics Processing and Phenomena</i> , 1997, 15, 1254.	1.6	9
57	Atomic nitrogen doping in p-ZnSe molecular beam epitaxial growth with almost 100% activation ratio. <i>Applied Physics Letters</i> , 1997, 71, 1077-1079.	3.3	9
58	Defect generation in layer-by-layer-grown ZnSe films on Te-terminated GaAs(001) surfaces. <i>Physical Review B</i> , 1998, 57, 1410-1413.	3.2	9
59	Growth mode of In _x Ga _{1-x} As(0<x<~0.5) on GaAs(001) under As-deficient conditions. <i>Physical Review B</i> , 2002, 65, .	3.2	9
60	Reflectance-difference studies of interface-formation and initial-growth processes in ZnSe/GaAs(001) heteroepitaxy. <i>Journal of Vacuum Science & Technology</i> an Official Journal of the American Vacuum Society B, <i>Microelectronics Processing and Phenomena</i> , 1997, 15, 1212.	1.6	8
61	Atomic nitrogen doping in p-ZnSe with high activation ratio using a high-power plasma source. <i>Journal of Crystal Growth</i> , 1998, 184-185, 411-414.	1.5	8
62	In situobservation of strain-induced optical anisotropy of ZnS _x Se _{1-x} /GaAs(110)during molecular-beam epitaxy. <i>Physical Review B</i> , 1999, 60, 8909-8914.	3.2	8
63	Atomic layer epitaxy processes of ZnSe on GaAs(001) as observed by beam-rocking reflection high-energy electron diffraction (RHEED) and total-reflection-angle X-ray spectroscopy (TRAXS). <i>Journal of Crystal Growth</i> , 1999, 201-202, 490-493.	1.5	7
64	Strain-induced surface segregation in In _{0.5} Ga _{0.5} As/GaAs heteroepitaxy. <i>Applied Physics Letters</i> , 2002, 80, 3931-3933.	3.3	7
65	Anisotropic kinetics on growing Ge(0 0 1) surfaces. <i>Surface Science</i> , 2009, 603, 826-830.	1.9	6
66	Heteroepitaxy of MoSe ₂ on Si(111) substrates: Role of surface passivation. <i>Applied Physics Letters</i> , 2019, 114, .	3.3	6
67	Polar surface dependence of epitaxy processes: ZnSe on GaAs{111}A, B-(2Å—2). <i>Applied Surface Science</i> , 1998, 130-132, 398-402.	6.1	5
68	Structure of Ga-stabilized GaAs(0 0 1) surfaces at high temperatures. <i>Applied Surface Science</i> , 2003, 212-213, 146-150.	6.1	5
69	Atomic-scale characterization of the N incorporation on GaAs(001). <i>Journal of Applied Physics</i> , 2011, 110, 033506.	2.5	5
70	Polarization Anisotropies in Strain-Free, Asymmetric, and Symmetric Quantum Dots Grown by Droplet Epitaxy. <i>Nanomaterials</i> , 2021, 11, 443.	4.1	5
71	Variable stoichiometry in Sb-induced(2Å—4)reconstructions on GaAs(001). <i>Physical Review B</i> , 2009, 80, .	3.2	4
72	Strain Relaxation in GaSb/GaAs(111)A Heteroepitaxy Using Thin InAs Interlayers. <i>ACS Omega</i> , 2018, 3, 15592-15597.	3.5	4

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73	Structure and morphology of 2H-MoTe ₂ monolayer on GaAs(111)B grown by molecular-beam epitaxy. <i>Npj 2D Materials and Applications</i> , 2022, 6, .	7.9	4
74	Heterovalent ZnSe/GaAs Interfaces. <i>Physica Status Solidi (B): Basic Research</i> , 1997, 202, 657-668.	1.5	3
75	Proposal of Selective Growth Technique Using Periodic Strain Field Caused by Misfit Dislocations. <i>Japanese Journal of Applied Physics</i> , 2004, 43, L1422-L1424.	1.5	3
76	Mn-Induced Surface Reconstructions on GaAs(001). <i>Journal of Physical Chemistry C</i> , 2016, 120, 6050-6062.	3.1	3
77	Annealing-Induced Structural Evolution of InAs Quantum Dots on InP (111)A Formed by Droplet Epitaxy. <i>Crystal Growth and Design</i> , 2021, 21, 3947-3953.	3.0	3
78	Initial growth processes of Ag on polar and non-polar semiconductor substrates. <i>Surface Science</i> , 1997, 380, L437-L440.	1.9	2
79	Adsorption processes of Se on the GaAs(111)A ^(2x2) surface. <i>Applied Surface Science</i> , 2000, 162-163, 419-424.	6.1	2
80	Large anisotropy in thermal atomic vibrations at the InSb(111)A ⁽²⁻²⁾ surface. <i>Physical Review B</i> , 2003, 68, .	3.2	2
81	Ge-induced reconstruction on GaAs(001): A precursor to As segregation. <i>Physical Review B</i> , 2008, 77, .		
82	Relationships between Interface Structures and Electrical Properties in the High-k/III ^V System. <i>Materials Research Society Symposia Proceedings</i> , 2009, 1194, 68.	0.1	2
83	Effect of Interface Oxidation on the Electrical Characteristics of HfO ₂ /Ultrathin-Epitaxial-Ge/GaAs(100) Structures. <i>Applied Physics Express</i> , 2010, 3, 035701.	2.4	2
84	Impact of Cation Surface Termination on the Electrical Characteristics of HfO ₂ /InGaAs(001) Metal-Oxide-Semiconductor Capacitors. <i>Japanese Journal of Applied Physics</i> , 2011, 50, 10PD01.	1.5	2
85	Controlling Anion Composition at Metal-Oxide-Semiconductor Interfaces on III ^V Channels by Plasma Processing. <i>Japanese Journal of Applied Physics</i> , 2012, 51, 065701.	1.5	2
86	Impact of Cation Surface Termination on the Electrical Characteristics of HfO ₂ /InGaAs(001) Metal-Oxide-Semiconductor Capacitors. <i>Japanese Journal of Applied Physics</i> , 2011, 50, 10PD01.	1.5	2
87	Molecular beam epitaxial growth of P-ZnSe:N using a novel plasma source. <i>Journal of Electronic Materials</i> , 1997, 26, 705-709.	2.2	1
88	Indium supply from triisopropylindium onto a GaAs(001) surface at room temperature. <i>Applied Physics Letters</i> , 2002, 81, 4058-4060.	3.3	1
89	RHEED Studies of GaAs Surface Structure. <i>Hyomen Kagaku</i> , 2003, 24, 136-144.	0.0	0
90	Cation-anion mixed-dimer structure of Al-induced (2-4) reconstruction on InAs(001). <i>Surface Science</i> , 2012, 606, 1886-1891.	1.9	0

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91	First-principles study of locally disordered structures of Mn-induced GaAs(001)-(2 Å– 2) surface. Japanese Journal of Applied Physics, 2016, 55, 08NB21.	1.5	0